

PATENT

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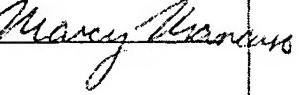
Applicants	Ishiduka, et al.	Examiner:	Johnson, Connie P.
Application No.:	10/591,718	Group Art Unit:	1795
Confirmation No:	3280	Docket:	1608-7 PCT/US
Filed:	September 5, 2006	Dated:	October 27, 2008
For:	POSITIVE-TYPE RESIST COMPOSITION FOR LIQUID IMMERSION LITHOGRAPHY AND METHOD FOR FORMING RESIST PATTERN		

Commissioner for Patents
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Dated: October 27, 2008

Signature: Marcy Mancuso 

AMENDMENT AND RESPONSE PURSUANT TO 37 C.F.R. §1.111

Sir:

In response to the non-final Office Action dated July 28, 2008, the due date for which is October 28, 2008.

Remarks begin on page 2 of this submission.